

METHOD OF FORMING TRANSPARENT CONDUCTIVE LAYER ON SUBSTRATE

ABSTRACT OF THE DISCLOSURE

5 A method of forming a transparent conductive layer on a substrate has the
steps of: forming a transparent conductive layer on a flat surface of a temporary
substrate, wherein the transparent conductive layer has a first side attached onto the flat
surface directly and a second side opposite to the first side; patterning the transparent
conductive layer; providing an insulation layer to cover the second side of the
10 transparent conductive layer; providing a substrate on the insulation layer, and
removing the temporary substrate to expose the first side of the transparent conductive
layer.